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APPARATUS AND METHOD OF
MANUFACTURING THE SAME****Publication Classification**

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(57) **ABSTRACT**

Provided is an organic light-emitting display apparatus. The organic light-emitting display apparatus includes: a substrate; an organic light-emitting device provided on the substrate and comprising a first electrode, a second electrode, and an intermediate layer provided between the first electrode and the second electrode; an encapsulation layer covering the organic light-emitting device; a base layer disposed under the substrate and having a pin hole formed therein; and a thermal conductive layer filling the pin hole.

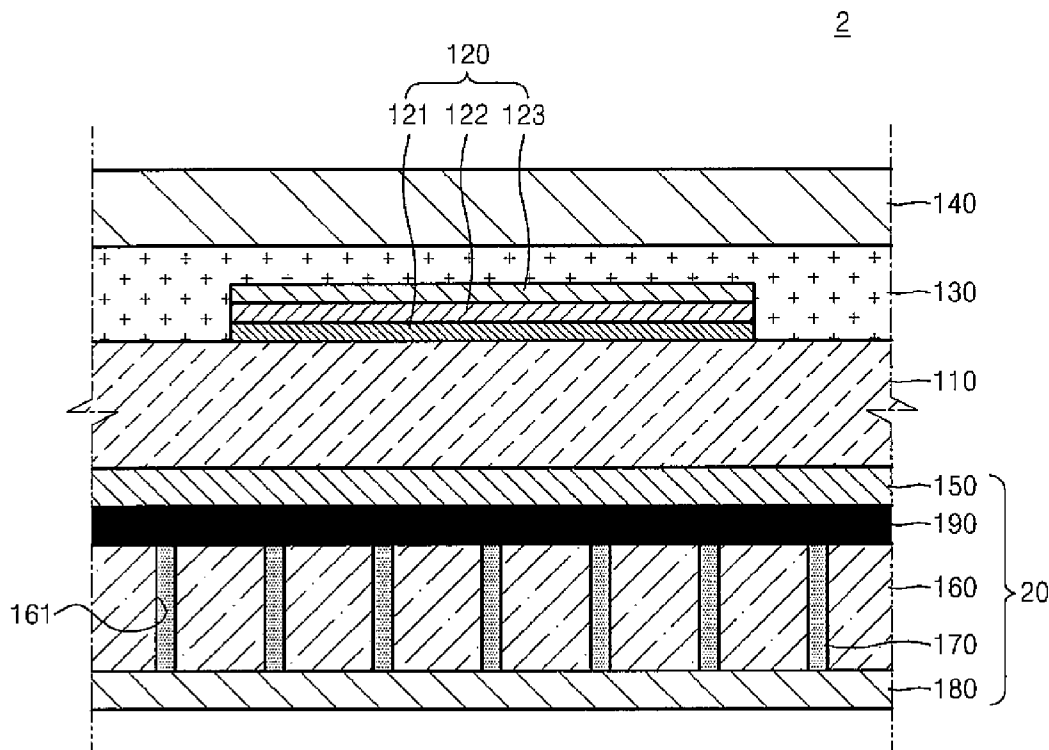


FIG. 1

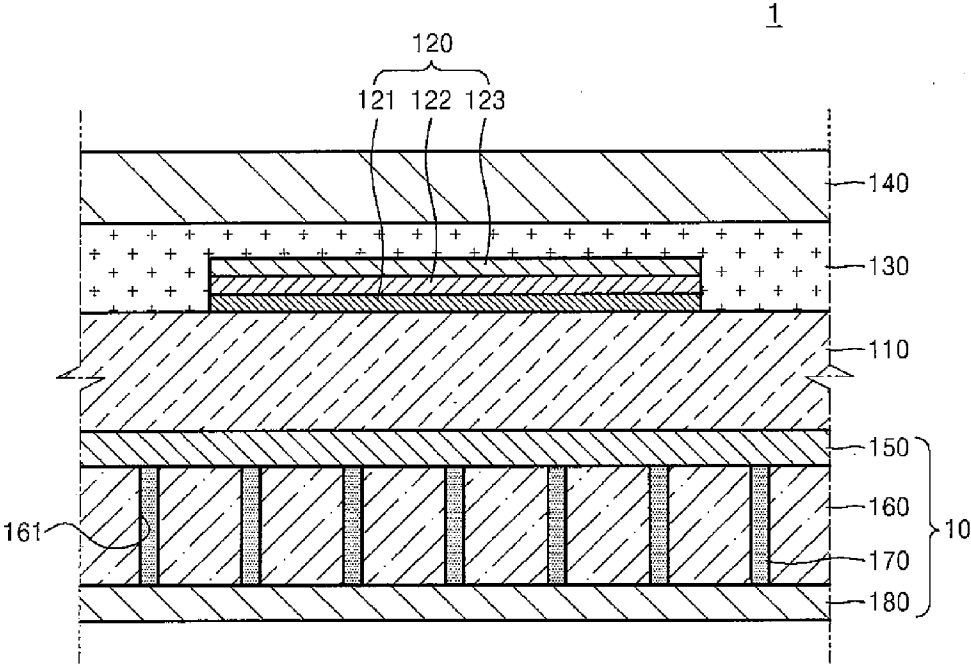


FIG. 2

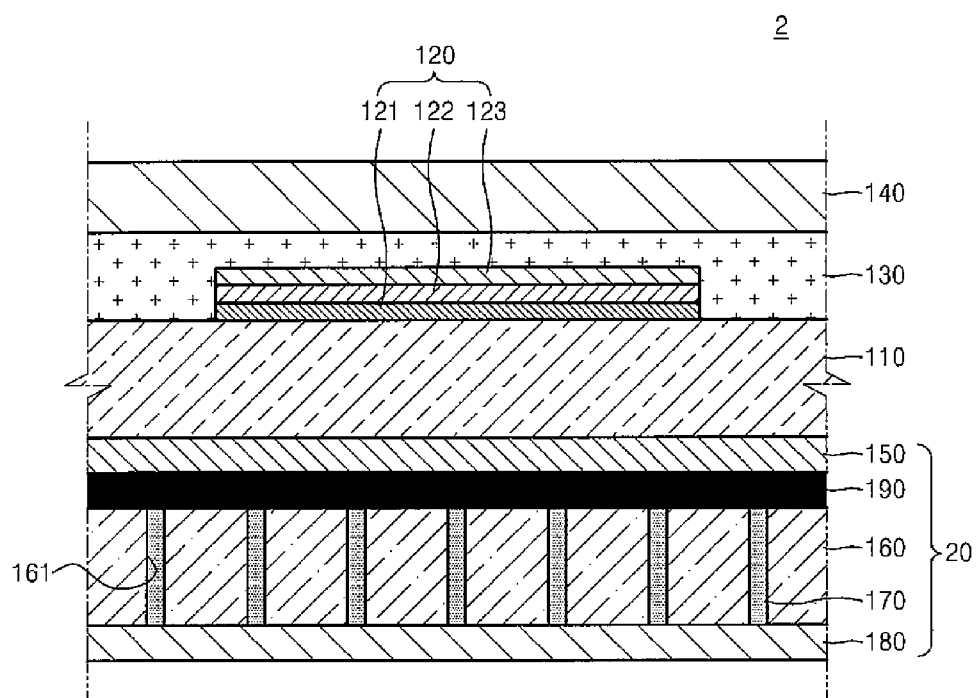


FIG. 3a

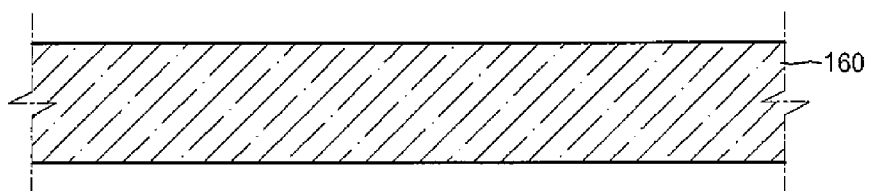


FIG. 3b

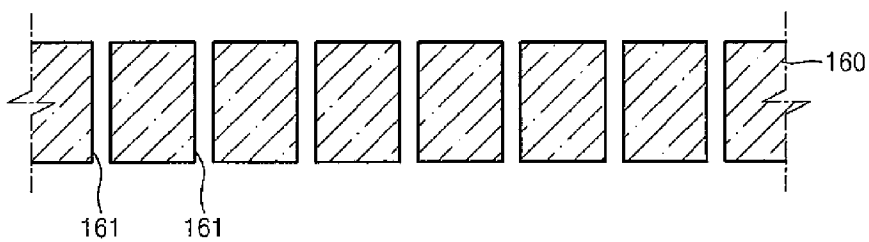


FIG. 3c

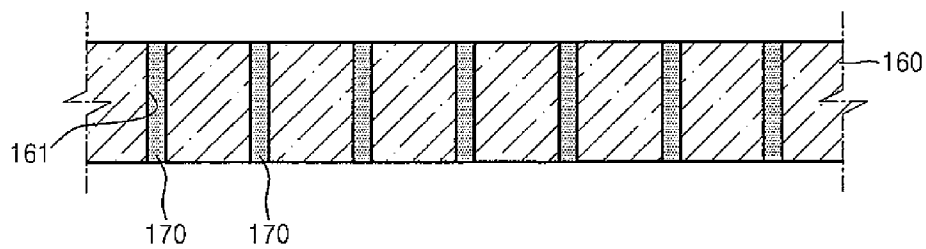


FIG. 3d

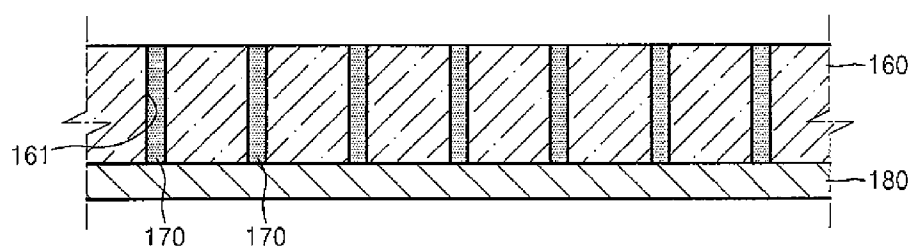


FIG. 3e

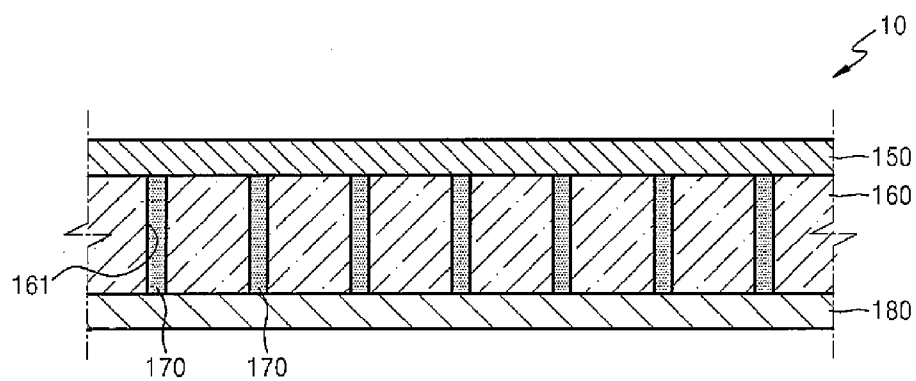
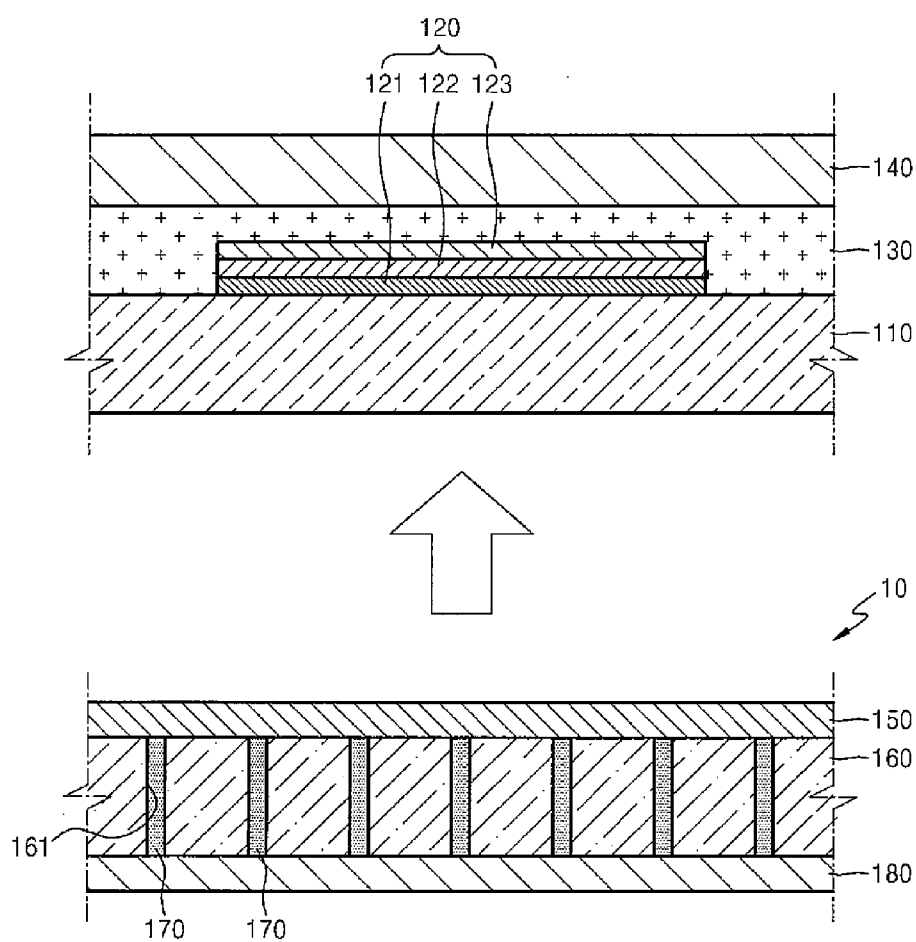


FIG. 3f



ORGANIC LIGHT-EMITTING DISPLAY APPARATUS AND METHOD OF MANUFACTURING THE SAME

RELATED APPLICATIONS

[0001] This application claims the benefit of Korean Patent Application No. 10-2014-0006262, filed on Jan. 17, 2014, in the Korean Intellectual Property Office, the disclosure of which is incorporated herein in its entirety by reference.

BACKGROUND

[0002] 1. Field

[0003] One or more embodiments of the present invention relate to organic light-emitting display apparatuses and methods of manufacturing the same.

[0004] 2. Description of the Related Art

[0005] An organic light-emitting display apparatus is a self-luminous display apparatus that includes a hole injection electrode, an electron injection electrode, and an organic emission layer formed therebetween and emits light when holes injected from an anode and electrons injected from a cathode are recombined in the organic emission layer.

[0006] Also, of portable electronic apparatuses, the organic light-emitting display apparatus is attracting attention as a next-generation display apparatus because it has high-quality characteristics such as low power consumption, high luminance, and high response speeds.

[0007] However, the organic light-emitting display apparatus has limits in portability and screen size when it uses a glass substrate that is heavy and fragile.

[0008] Therefore, a flexible organic light-emitting display apparatus is being developed by using a flexible substrate such as plastic. Accordingly, it is necessary to protect the inside of a display panel and the surface of a flexible substrate such as plastic.

SUMMARY

[0009] One or more embodiments of the present invention include organic light-emitting display apparatuses that have an improved heat dissipation function and a reduced thickness.

[0010] One or more embodiments of the present invention include methods of manufacturing the organic light-emitting display apparatuses.

[0011] Additional aspects will be set forth in part in the description which follows and, in part, will be apparent from the description, or may be learned by practice of the presented embodiments.

[0012] According to one or more embodiments of the present invention, an organic light-emitting display apparatus includes: a substrate; an organic light-emitting device provided on the substrate and including a first electrode, a second electrode, and an intermediate layer provided between the first electrode and the second electrode; an encapsulation layer covering the organic light-emitting device; a base layer disposed under the substrate and having a pin hole formed therein; and a thermal conductive layer filling the pin hole.

[0013] The organic light-emitting display apparatus may further include a polarization layer disposed on the encapsulation layer.

[0014] The organic light-emitting display apparatus may further include an adhesive layer formed between the substrate and the base layer to join the substrate and the base layer.

[0015] The organic light-emitting display apparatus may further include a light blocking layer disposed between the adhesive layer and the base layer.

[0016] The organic light-emitting display apparatus may further include a heat dissipation layer formed under the base layer to dissipate heat discharged through the thermal conductive layer.

[0017] The heat dissipation layer may include a transparent conductive layer.

[0018] The heat dissipation layer may include indium tin oxide (ITO) or carbon nanotube (CNT).

[0019] The pin hole may be formed in plurality.

[0020] The thermal conductive layer may include copper (Cu) or graphite.

[0021] According to one or more embodiments of the present invention, a method of manufacturing an organic light-emitting display apparatus includes: forming a pin hole in a base layer; forming a thermal conductive layer in a pin hole; forming an adhesive layer on the base layer; and joining the base layer to a substrate, on which an organic light-emitting device is disposed, by the adhesive layer.

[0022] The method may further include forming a heat dissipation layer on the base layer.

[0023] The base layer may be disposed between the adhesive layer and the heat dissipation layer.

[0024] The heat dissipation layer may include a transparent conductive layer.

[0025] The heat dissipation layer may include indium tin oxide (ITO) or carbon nanotube (CNT).

[0026] The method may further include forming a light blocking layer on the base layer.

[0027] The light blocking layer may be disposed between the adhesive layer and the base layer.

[0028] The pin hole may be formed in plurality.

[0029] The thermal conductive layer may include copper (Cu) or graphite.

BRIEF DESCRIPTION OF THE DRAWINGS

[0030] These and/or other aspects will become apparent and more readily appreciated from the following description of the embodiments, taken in conjunction with the accompanying drawings in which:

[0031] FIG. 1 is a cross-sectional view of an organic light-emitting display apparatus according to an embodiment of the present invention;

[0032] FIG. 2 is a cross-sectional view of an organic light-emitting display apparatus according to another embodiment of the present invention; and

[0033] FIGS. 3A to 3F are cross-sectional views illustrating a method of manufacturing the organic light-emitting display apparatus of FIG. 1, according to an embodiment of the present invention.

DETAILED DESCRIPTION

[0034] Reference will now be made in detail to embodiments, examples of which are illustrated in the accompanying drawings, wherein like reference numerals refer to like elements throughout. In this regard, the present embodiments may have different forms and should not be construed as

being limited to the descriptions set forth herein. Accordingly, the embodiments are merely described below, by referring to the figures, to explain aspects of the present description. As used herein, expressions such as “at least one of,” when preceding a list of elements, modify the entire list of elements and do not modify the individual elements of the list.

[0035] The present invention may include various embodiments and modifications, and exemplary embodiments thereof are illustrated in the drawings and will be described herein in detail. The effects and features of the present invention and the accomplishing methods thereof will become apparent from the following description of the embodiments, taken in conjunction with the accompanying drawings. However, the present invention is not limited to the embodiments described below, and may be embodied in various modes.

[0036] Hereinafter, embodiments of the present invention will be described in detail with reference to the accompanying drawings. In the following description, like reference numerals denote like elements, and a redundant description thereof will be omitted.

[0037] It will be understood that although the terms “first”, “second”, etc. may be used herein to describe various components, these components should not be limited by these terms. These terms are only used to distinguish one component from another.

[0038] As used herein, the singular forms “a”, “an” and “the” are intended to include the plural forms as well, unless the context clearly indicates otherwise.

[0039] It will be further understood that the terms “comprise”, “include” and “have” used herein specify the presence of stated features or components, but do not preclude the presence or addition of one or more other features or components.

[0040] It will be understood that when a layer, region, or component is referred to as being “formed on” another layer, region, or component, it may be directly or indirectly formed on the other layer, region, or component. That is, for example, intervening layers, regions, or components may be present.

[0041] Sizes of components in the drawings may be exaggerated for convenience of description. In other words, since sizes and thicknesses of components in the drawings are arbitrarily illustrated for convenience of description, the following embodiments are not limited thereto.

[0042] Hereinafter, exemplary embodiments of the present invention will be described in detail with reference to the accompanying drawings.

[0043] FIG. 1 is a cross-sectional view of an organic light-emitting display apparatus 1 according to an embodiment of the present invention. Referring to FIG. 1, the organic light-emitting display apparatus 1 includes a substrate 110, an organic light-emitting device 120 provided on the substrate 110, an encapsulation layer 130 covering the organic light-emitting device 120, a polarization layer 140 disposed on the encapsulation layer 130, and a protection film 10 disposed under the substrate 110.

[0044] The protection film 10 includes a base layer 160 having a pin hole 161 formed therein, a thermal conductive layer 170 filling the pin hole 161, an adhesive layer 150 formed between the substrate 110 and the base layer 160, and a heat dissipation layer 180 formed under the base layer 160.

[0045] The substrate 110 may be a substrate that is used in a general organic light-emitting device. For example, the substrate 110 may be a glass substrate or a plastic substrate that is excellent in mechanical strength, thermal stability,

transparency, surface smoothness, handleability, and waterproofness. Although not illustrated in FIG. 1, as an example of various modifications, a planarization layer and an insulating layer may be further provided on the substrate 110.

[0046] The organic-light emitting device 120 is provided on the substrate 110. The organic light-emitting device 120 includes a first electrode 121, an intermediate layer 122, and a second electrode 123.

[0047] The first electrode 121 may be formed by vacuum deposition or sputtering, and may be a cathode or an anode. The first electrode 21 may be a transparent electrode, a semi-transparent electrode, or a reflective electrode, and may be formed of indium tin oxide (ITO), indium zinc oxide (IZO), tin oxide (SnO₂), zinc oxide (ZnO), aluminum (Al), silver (Ag), or magnesium (Mg); however, embodiments of the present invention are not limited thereto. Also, as an example of various modifications, the first electrode 121 may have a two or more-layered structure using two or more different materials.

[0048] The second electrode 123 may be formed by vacuum deposition or sputtering, and may be a cathode or an anode. The second electrode 123 may be formed of a metal having a low work function, an alloy, a conductive compound, or a mixture thereof. For example, the second electrode 123 may be formed of lithium (Li), magnesium (Mg), aluminum (Al), aluminum-lithium (Al—Li), calcium (Ca), magnesium-indium (Mg—In), or magnesium-silver (Mg—Ag). Also, as an example of various modifications, the second electrode 123 may have a two or more-layered structure using two or more different materials.

[0049] The intermediate layer 122 is provided between the first electrode 121 and the second electrode 123. The intermediate layer 122 includes an organic emission layer. As another example, the intermediate layer 122 includes an organic emission layer and may further include at least one of a hole injection layer (HIL), a hole transport layer (HTL), an electron transport layer (ETL), and an electron injection layer (EIL). However, the present embodiment is not limited thereto, and the intermediate layer 122 includes an organic emission layer and may further include other various functional layers.

[0050] A protection layer (not illustrated) may be further provided on the organic light-emitting device 120. The protection layer may be formed of an organic material or an inorganic material that may prevent the second electrode 123 of the organic light-emitting device 120 from being oxidized by moisture and oxygen. Also, as an example of various modifications, the protection layer may be formed of a compound of an organic material and an inorganic material.

[0051] The encapsulation layer 130 is formed on the substrate 110 to encapsulate the organic light-emitting device 120. The encapsulation layer 130 may include a plurality of inorganic layers, or may include an inorganic layer and an organic layer.

[0052] The organic layer of the encapsulation layer 130 is formed of a polymer and may be a single layer or a layer stack formed of any one of polyethylene terephthalate, polyimide, polycarbonate, epoxy, polyethylene, and polyacrylate. The organic layer may be formed of polyacrylate, and in detail, may include a polymerized monomer composition including a diacrylate-based monomer and a triacrylate-based monomer. The monomer composition may further include a monoacrylate-based monomer. Also, the monomer composition may further include a well-known photoinitiator such as

trimethyl benzoyl diphenyl phosphine oxide (TPO), but embodiments of the present invention are not limited thereto.

[0053] The inorganic layer of the encapsulation layer **130** may be a single layer or a layer stack including a metal oxide and a metal nitride. In detail, the inorganic layer may include any one of SiN_x , Al_2O_3 , SiO_2 , and TiO_2 .

[0054] A top layer of the encapsulation layer **130**, which is exposed to the outside, may be formed of an inorganic layer in order to prevent the permeation of moisture into the organic light-emitting device **120**.

[0055] The encapsulation layer **130** may include at least one sandwich structure in which at least one organic layer is inserted between at least two inorganic layers. As another example, the encapsulation layer **130** may include at least one sandwich structure in which at least one inorganic layer is inserted between at least two organic layers. As another example, the encapsulation layer **130** may include a sandwich structure in which at least one organic layer is inserted between at least two inorganic layers and a sandwich structure in which at least one inorganic layer is inserted between at least two organic layers.

[0056] The encapsulation layer **130** may include a first inorganic layer, a first organic layer, and a second inorganic layer that are sequentially formed from the top portion of the organic light-emitting device **120**.

[0057] As another example, the encapsulation layer **130** may include a first inorganic layer, a first organic layer, a second inorganic layer, a second organic layer, and a third inorganic layer that are sequentially formed from the top portion of the organic light-emitting device **120**.

[0058] As another example, the encapsulation layer **130** may include a first inorganic layer, a first organic layer, a second inorganic layer, a second organic layer, a third inorganic layer, a third organic layer, and a fourth inorganic layer that are sequentially formed from the top portion of the organic light-emitting device **120**.

[0059] A halogenized thermal conductive layer, including a lithium fluoride (LiF), may be additionally included between the organic light-emitting device **120** and the first inorganic layer. The halogenized thermal conductive layer may prevent the organic light-emitting device **120** from being damaged when the first inorganic layer is formed by sputtering or plasma deposition.

[0060] An area of the first organic layer may be smaller than that of the second inorganic layer, and an area of the second organic layer may be smaller than that of the third inorganic layer.

[0061] As another example, the first organic layer may be completely covered by the second inorganic layer, and the second organic layer may be completely covered by the third inorganic layer.

[0062] The polarization layer **140** may be formed on the encapsulation layer **130**. The polarization layer **140** may be formed of a polarization film. The polarization layer **140** may be formed of a metal-dielectric multilayer.

[0063] The encapsulation layer **130** and the polarization layer **140** become thinner. Since the encapsulation layer **130** and the polarization layer **140** become thinner, it is necessary to reduce the thickness of the protection film **10** disposed under the substrate **110**, in order to form a neutral plane near the organic light-emitting device **120** when the organic light-emitting display apparatus **1** is bent. A vertical stress is generated at a section of a beam by a bending moment, and the

neutral plane refers to a plane that has no normal stress generated therein, that is, a plane that does not extend or shorten

[0064] The protection film **10** is disposed under the substrate **110**. The protection film **10** may include the adhesive layer **150**, the base layer **160**, the thermal conductive layer **170**, and the heat dissipation layer **180**.

[0065] The base layer **160** is disposed under the substrate **110**. The pin hole **161** is formed in the base layer **160**. The base layer **160** may include a material such as polyethylene terephthalate (PET), polycarbonate (PC), polyethylene naphthalate (PEN), or cyclo-olefin polymer (COP). The pin hole **161** may be formed in plurality.

[0066] The thermal conductive layer **170** may fill the pin hole **161**. The thermal conductive layer **170** may be formed of a material having high thermal conductivity. The thermal conductive layer **170** may include copper (Cu) or graphite. Since the thermal conductive layer **170** fills the pin hole **161**, heat generated by the substrate **110** may be efficiently discharged through the thermal conductive layer **170** filling the pin hole **161**. When the pin hole **161** is formed in plurality, since the thermal conductive layers **170** are also formed in the shape of a plurality of pillars, the heat may be discharged more efficiently.

[0067] The adhesive layer **150** may be formed between the substrate **110** and the base layer **160**. The adhesive layer **150** may be formed to join the substrate **110** and the base layer **160**. The adhesive layer **150** may be formed of an acryl-based or urethane-based adhesive.

[0068] The heat dissipation layer **180** may be formed under the base layer **160**. The heat dissipation layer **180** may be formed of a material having a good heat dissipation function. The heat dissipation layer **180** may be formed of a transparent conductive layer. The heat dissipation layer **180** may include ITO or carbon nanotubes (CNT). The heat dissipation layer **180** may be formed under the base layer **160** to dissipate heat that is discharged through the thermal conductive layer **170**.

[0069] Since the pin hole **161** of the base layer **160** is filled with the thermal conductive layer **170** and the heat dissipation layer **180** is formed under the base layer **160**, a heat dissipation function may be improved. Also, according to the present embodiment, since only a thickness of the heat dissipation layer **180** is added under the base layer **160**, the thickness of the protection film **10** may be reduced as compared with the related art case where a Cu tape and graphite are additionally formed under a base film in order to provide thermal conduction and heat dissipation.

[0070] FIG. 2 is a cross-sectional view of an organic light-emitting display apparatus **2** according to another embodiment of the present invention.

[0071] Hereinafter, the present embodiment will be described focusing on a difference from the embodiment of FIG. 1. Herein, like reference numerals denote like elements throughout FIGS. 1 and 2.

[0072] Referring to FIG. 2, the organic light-emitting display apparatus **2** includes a substrate **110**, an organic light-emitting device **120** provided on the substrate **110**, an encapsulation layer **130** covering the organic light-emitting device **120**, a polarization layer **140** disposed on the encapsulation layer **130**, and a protection film **20** disposed under the substrate **110**. The protection film **20** includes a base layer **160** having a pin hole **161** formed therein, a thermal conductive layer **170** filling the pin hole **161**, an adhesive layer **150** formed between the substrate **110** and the base layer **160**, a heat dissipation layer **180** formed under the base layer **160**,

and a light blocking layer **190** formed between the adhesive layer **150** and the base layer **160**.

[0073] The light blocking layer **190** may be formed between the adhesive layer **150** and the base layer **160**. The light blocking layer **190** may be formed of a material that may block light. The light blocking layer **190** may be formed by adding ink to a material such as PET, P/c, PEN, or COP. The exposure of a pattern under a display panel may be prevented by the light blocking layer **190**.

[0074] Hereinafter, a method of manufacturing the organic light-emitting display apparatus **1** of FIG. **1** will be described with reference to FIGS. **3A** to **3F**.

[0075] First, as illustrated in FIG. **3A**, a base layer **160** is prepared.

[0076] Thereafter, as illustrated in FIG. **3B**, a pin hole **161** is formed in the base layer **160**. The pin hole **161** may be formed in plurality.

[0077] Thereafter, as illustrated in FIG. **3C**, a thermal conductive layer **170** is formed to fill the pin hole **161**. When the thermal conductive layer **170** is formed of a metal, the thermal conductive layer **170** may be formed by metal layer deposition.

[0078] Thereafter, as illustrated in FIG. **3D**, a heat dissipation layer **180** is formed on the base layer **160**. The heat dissipation layer **180** may be formed of a transparent conductive layer. The heat dissipation layer **180** may be formed by coating or deposition.

[0079] Thereafter, as illustrated in FIG. **3E**, an adhesive layer **150** is formed on the base layer **160**. Accordingly, a protection film **10** according to an embodiment may be completed. Also, although not illustrated in the drawings, a light blocking layer **190** may be formed directly on the base layer **160** before forming the adhesive layer **150**.

[0080] When the adhesive layer **150** is formed on the light blocking layer **190**, a protection film **20** according to another embodiment may be completed.

[0081] Thereafter, as illustrated in FIG. **3F**, the protection film **10** according to an embodiment is joined to the substrate **110**, on which the organic light-emitting device **120** is formed, by the adhesive layer **150**. Accordingly, the organic light-emitting display apparatus **1** according to an embodiment of the present invention may be manufactured. Also, although not illustrated in the drawings, by joining the protection film **20** according to another embodiment to the substrate **110**, on which the organic light-emitting device **120** is formed, by the adhesive layer **150**, the organic light-emitting display apparatus **2** according to another embodiment of the present invention may be manufactured.

[0082] As described above, according to the one or more of the above embodiments of the present invention, slim organic light-emitting display apparatuses having an improved heat dissipation function may be embodied.

[0083] It should be understood that the exemplary embodiments described herein should be considered in a descriptive sense only and not for purposes of limitation. Descriptions of features or aspects within each embodiment should typically be considered as available for other similar features or aspects in other embodiments.

[0084] While one or more embodiments of the present invention have been described with reference to the figures, it will be understood by those of ordinary skill in the art that various changes in form and details may be made therein without departing from the spirit and scope of the present invention as defined by the following claims.

What is claimed is:

1. An organic light-emitting display apparatus comprising: a substrate; an organic light-emitting device provided on the substrate and comprising a first electrode, a second electrode, and an intermediate layer provided between the first electrode and the second electrode; an encapsulation layer covering the organic light-emitting device; a base layer disposed under the substrate and having a pin hole formed therein; and a thermal conductive layer filling the pin hole.
2. The organic light-emitting display apparatus of claim 1, further comprising a polarization layer disposed on the encapsulation layer.
3. The organic light-emitting display apparatus of claim 1, further comprising an adhesive layer formed between the substrate and the base layer to join the substrate and the base layer.
4. The organic light-emitting display apparatus of claim 3, further comprising a light blocking layer disposed between the adhesive layer and the base layer.
5. The organic light-emitting display apparatus of claim 1, further comprising a heat dissipation layer formed under the base layer to dissipate heat discharged through the thermal conductive layer.
6. The organic light-emitting display apparatus of claim 5, wherein the heat dissipation layer comprises a transparent conductive layer.
7. The organic light-emitting display apparatus of claim 6, wherein the heat dissipation layer comprises indium tin oxide (ITO) or carbon nanotube (CNT).
8. The organic light-emitting display apparatus of claim 1, wherein the pin hole is formed in plurality.
9. The organic light-emitting display apparatus of claim 1, wherein the thermal conductive layer comprises copper (Cu) or graphite.
10. A method of manufacturing an organic light-emitting display apparatus, the method comprising: forming a pin hole in a base layer; forming a thermal conductive layer in a pin hole; forming an adhesive layer on the base layer; and joining the base layer to a substrate, on which an organic light-emitting device is disposed, by the adhesive layer.
11. The method of claim 10, further comprising forming a heat dissipation layer on the base layer.
12. The method of claim 11, wherein the base layer is disposed between the adhesive layer and the heat dissipation layer.
13. The method of claim 11, wherein the heat dissipation layer comprises a transparent conductive layer.
14. The method of claim 13, wherein the heat dissipation layer comprises indium tin oxide (ITO) or carbon nanotube (CNT).
15. The method of claim 10, further comprising forming a light blocking layer on the base layer.
16. The method of claim 15, wherein the light blocking layer is disposed between the adhesive layer and the base layer.
17. The method of claim 10, wherein the pin hole is formed in plurality.
18. The method of claim 10, wherein the thermal conductive layer comprises copper (Cu) or graphite.

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